



# Electromigration on Signal Interconnects (20140089, Dr. Sachin Sapatnekar)

## Efficiently Characterizes Cell-internal Electromigration

The problem of cell-internal electromigration (EM) on signal interconnects within a standard cell is solved using this technology which efficiently characterizes EM characteristics of gates in a standard cell library, under all pin positions, based on a single circuit simulation and graph-based methods. The approach uses Joule heating effects to model and efficiently characterize cell-internal EM to analyze the lifetime of large benchmark circuits. A related method optimizes circuit lifetime by changing pin positions in gates within a circuit. This procedure has demonstrated an approximate 60% increase in circuit lifetime.

## Optimization of Circuit Lifetime

Standard cell-based gate libraries are the bedrock of integrated circuit design. Electromigration (EM) in on-chip metal interconnects is a critical reliability failure mechanism in nanometer-scale technologies and is an increasing problem in integrated circuits that reduces circuit lifetime. Traditionally, EM affected global wires, but in current and future technologies, within-gate wires will also be significantly affected. Currently, EM checks in existing technologies are performed ad hoc; no current methods systematically perform cell-internal EM or allocate pin positions to increase the lifetime of a circuit that uses numerous standard cells. This technology provides a systematic and computationally efficient way for analyzing cell-level EM and translating it to an analysis and optimization of circuit level lifetimes.

### BENEFITS AND FEATURES:

- Models and efficiently characterizes cell-internal EM
- Characterizes EM characteristics of gates in a standard cell library under all pin positions
- Analyzes lifetime of large benchmark circuits
- Optimizes circuit lifetime
- Joule heating effects
- Solves cell-internal EM problems
- Approximate 60% increase in circuit lifetime

### APPLICATIONS:

- Integrated circuit design
- Circuit design

**Phase of Development** - Prototype dev

### Researchers

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### Technology ID

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### Category

Engineering & Physical  
Sciences/Nanotechnology  
Engineering & Physical  
Sciences/Semiconductor  
Software & IT/Algorithms  
Software & IT/Simulation &  
Modeling

### Learn more



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## Publications

[A Systematic Approach for Analyzing and Optimizing Cell-Internal Signal Electromigration](#)

*IEEE/ACM International Conference on Computer-Aided Design, Digest of Technical Papers, ICCAD. 2015*, pp. 486 – 491, 2014

[Cell-Internal Electromigration: Analysis and Pin Placement Based Optimization](#)

*IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems*, Vol. 35, No. 2, pp. 220 – 231, February 2016

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